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Com	plete if Known
Application Number	10/554,208
Filing Date	October 24, 2005
First Named Inventor	Thomas RIESTER
Art Unit	2887
Examiner Name	Kim, Tae W.
Attorney Docket Number	502901-432PUS

				ENT DOCUMENTS		
Examiner Initials*	Cite	Document Number	Publication Date MM-DD-YYYY	Name of Patentee or Applicant of Cited Document	Pages, Columns, Lines, Where Relevant	
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	Examiner Signature	/Tae Kim/	Date Considered	04/24/2009			
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